

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

LABORATORY GROWN DIAMOND REPORT

LG611376423 Report verification at igi.org

LABORATORY GROWN DIAMOND REPORT

GRADING SCALES

CLARITY

| IF | VVS ¹⁻² | VS ¹⁻² | SI ¹⁻² | l ¹⁻³ |
|------------|--------------------|-------------------|-------------------|------------------|
| Internally | Very Very | Very | Slightly | Included |
| Flawless | Slightly Included | Slightly Included | Included | |

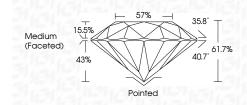
COLOR

| D | Е | F | G | Н | Т | J | Faint | Very Light | Light |
|---|---|---|---|---|---|---|-------|------------|-------|
| | | | | | | | | | |



IDEAL

LABORATORY GROWN DIAMOND REPORT



ADDITIONAL GRADING INFORMATION

Cut Grade

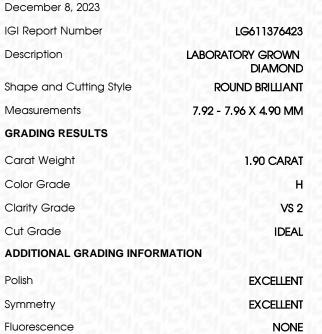
| Polish | EXCELLENT |
|--|----------------------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | (67) LG611376423 |
| Comments: This Laboratory created by Chemical Vapo process and may include p Type IIa | or Deposition (CVD) growth |



| ă | | NGN LG611 | own Diamond v cal Vapor Depo ass and may Ir ent. | |
|----------|--------------|----------------|--|--|
| Symmetry | Fluorescence | Inscription(s) | Comments: This Laboratory Grown Diamond w realed by Chamical Vapor Dep (CVD) growth process and may in post-growth treatment type lia | |

ostition octude

| PROPORTIONS |
|-------------|
| |
| |



1/3/1 LG611376423 Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa

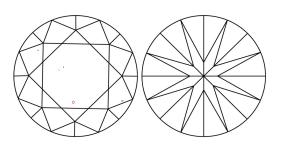
35.8° Medium 15.5% (Faceted) \checkmark 40.7° 43%

57%

Pointed

61.7%

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics. 150 LG611376423

Sample Image Used



© IGI 2020, International Gemological Institute

THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.